

Special Issue

Artificial Intelligence in the Process Industry

Message from the Guest Editors

This Special Issue on "Artificial Intelligence in the Process Industry" aims to summarize the latest progress in the methods and applications of AI in the process industry to address the uncertainty and complexity of the intelligent transformation in the future industrial sector. Topics will include, but are not limited to:

- Process synthesis and analysis;
- Process control and fault diagnosis;
- Process modeling and simulation;
- Industrial process optimization;
- Soft sensors;
- Digital twin;
- Smart factory;
- Smart manufacturing;
- Machine learning applications in the process industry.

Guest Editors

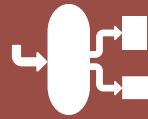
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Deadline for manuscript submissions

closed (15 December 2023)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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